



*Thin Film Measurement solution
Software, sensors, custom development
and integration*

SPECTROSCOPIC REFLECTANCE AND REFRACTIVE INDEX MEASUREMENT

Spectroscopic reflectance is a powerful method of thickness and optical constants measurement. The thickness of, practically, any translucent material in 1nm -1mm thickness range can be measured. Optical constants can be measured for material thicknesses 20nm -20 μ m. However, there is one limitation – in order to measure optical constants, material need to be absorbing ($k>0$). If material has $k=0$, thickness and refractive index cannot be measured independently – they are correlated. The $k>0$ requirement is easily understood intuitively – absorption constraints the thickness and thus de-correlates thickness and refractive index measurement.

One approach is to select wavelength range where $k>0$ (typically in UV). For example, SiN or TiO₂ have $k=0$ in the visible range but nice absorption edge in the UV, so using UVVis spectrum one can reliably determine thickness and n & k of these materials. Some materials, like SiO₂, are dielectric in a very wide spectral range but, in many cases, they have some surface roughness or non-uniformity that causes light scattering. Small light scattering has the effect similar to absorption and allows to determine thickness and R.I. independently especially in thicker films (several μ m).

There is one special case when R.I. of dielectric film can be determined very accurately along with the thickness without a need for absorption. This happens when there are 2 layers (or layer on substrate) that have similar R.I., one R.I. (e.g. substrate) is known and film is relatively thick (several μ m). For example, 16 μ m polymer film on glass (glass R.I. 1.5, polymer R.I. \sim 1.6).

Two figures below (Fig.1 and Fig. 2) show the effect of the R.I. on reflectance spectrum. Optical contrast (difference between R.I. of the materials) affects strongly the amplitude of interference fringes (peaks of constructive and destructive interference). The better is optical contrast – the stronger is amplitude. As a result, R.I. index can be determined independently – thickness has no effect on the amplitude of interference peaks. This allows us to determine R.I. and improve accuracy of thickness measurement at the same time.

Note. In this example, polymer was deposited on a thin glass (\sim 1.3mm) and backside reflectance of the glass was included in the model. This is typical to LCD applications. Polymer dispersion (R.I.) was represented using Cauchy approximation (see Fig. 3)

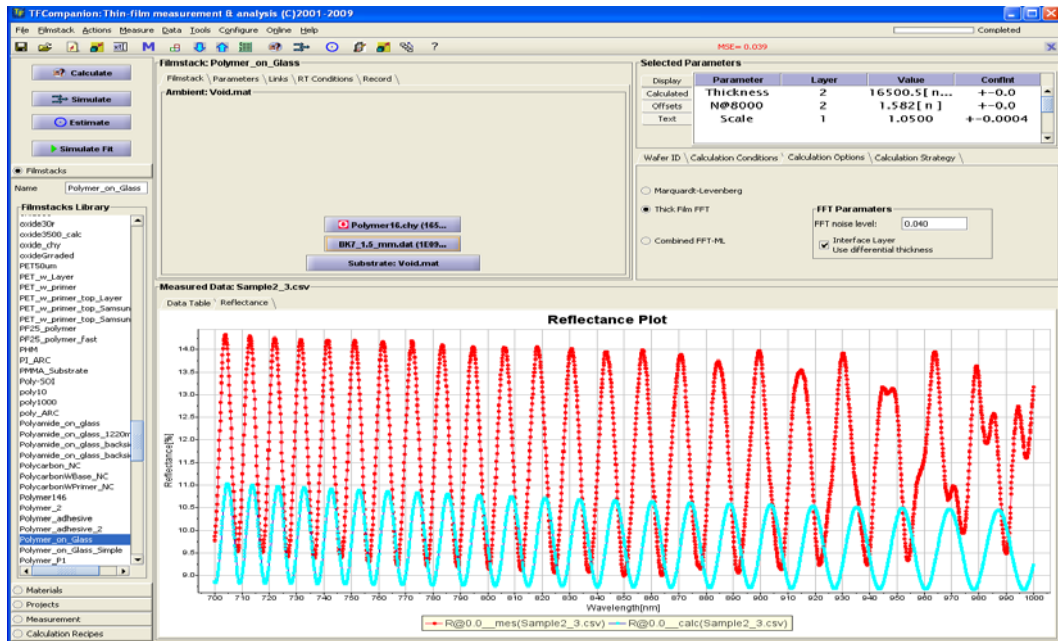


Fig. 1. Polymer on glass. Reflectance spectrum 700-1000nm. Fit between measured (RED) and model (Blue) data for polymer R.I.=1.582 at 800nm. Small amplitude of the model data shows that R.I. of the polymer is higher

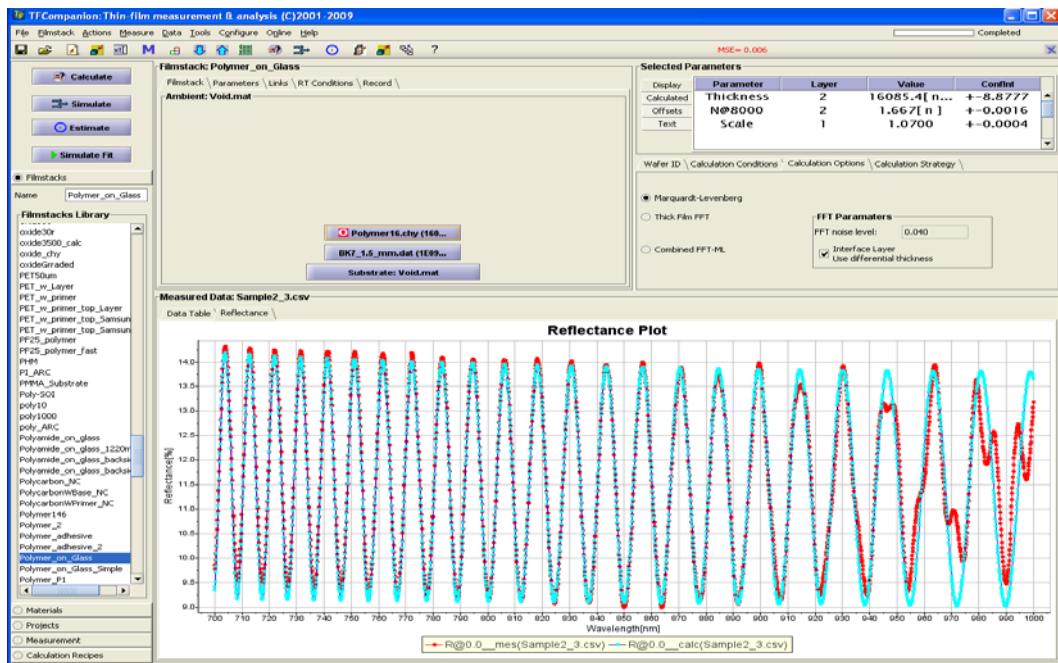


Fig. 2. Same as Fig.1 but polymer R.I. is adjusted to 1.667 at 800nm. . Fit between measured (RED) and model (Blue) data is good now. Both thickness and R.I. can be determined independently.

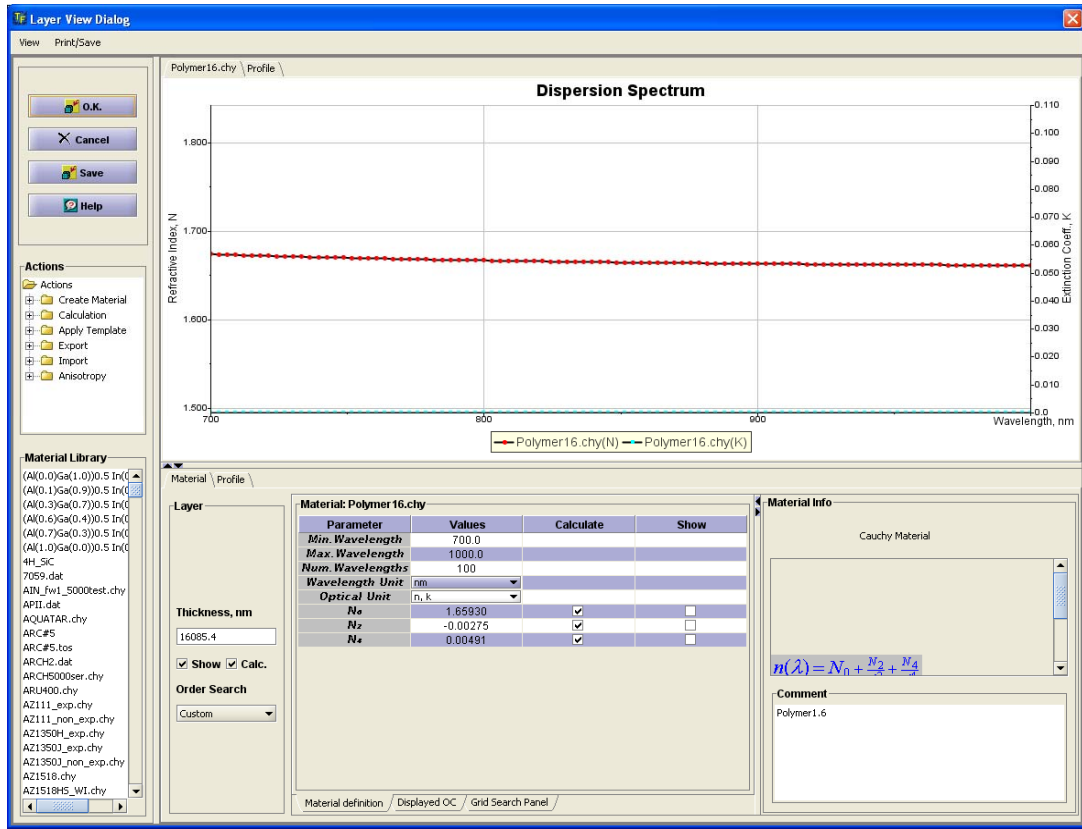


Fig. 3 R.I. of the polymer film (700-1000nm) determined from the measurement. R.I. dispersion is represented using Cauchy approximation